

5. DETERMINATION OF LATTICE PARAMETERS

primitive. This presents no difficulty in the non-zero-zone analysis given in Subsection 5.4.1.3 but needs consideration when two patterns are used as described in Subsection 5.4.1.2.

Unit-cell parameters may be partly or fully determined depending on the extent of knowledge of the effective camera length L and wavelength λ , and upon the type and number of patterns. The different situations are distinguished in Table 5.4.1.1 for photographic recording. Note that L is simply a magnification factor.

The accuracy of the non-zero-zone analysis described in Subsection 5.4.1.3 will depend on the influence of spiral, radial, and elliptical distortions. The camera length and wavelength need to be known to better than 1%.

For measurements made using microscope deflector systems, a knowledge of L may not be required depending on the location of the deflectors in the microscope column. Instead, the calibration factor of the deflectors, in suitable units, will replace L .

5.4.1.2. Zero-zone analysis

Two patterns are required that represent different sections through the reciprocal lattice. The angle of rotation p between these sections must be known, as well as the trace of the rotation axis in the plane of the pattern. Define the plane of the first pattern as the xy plane with the x axis, for convenience, coincident with the trace of the rotation axis. The coordinates x_0, y_0 of reflections in the first pattern are then measured. The coordinates x_1, y_1 of spots in the patterns rotated by p relative to the first pattern are then measured, care being taken to align the trace of the rotation axis with the x axis of the measuring equipment for each pattern. The coordinates of these reflections are then reduced to the coordinate system of the first pattern by the relations $x_0 = x_1, y_0 = y_1 \cos(p), z_0 = y_1 \sin(p)$. The coordinates of all reflections measured are placed in a table that is scanned to extract the three shortest non-coplanar vectors. If the patterns come from dense, neighbouring zones, it is likely that these vectors define a primitive cell.

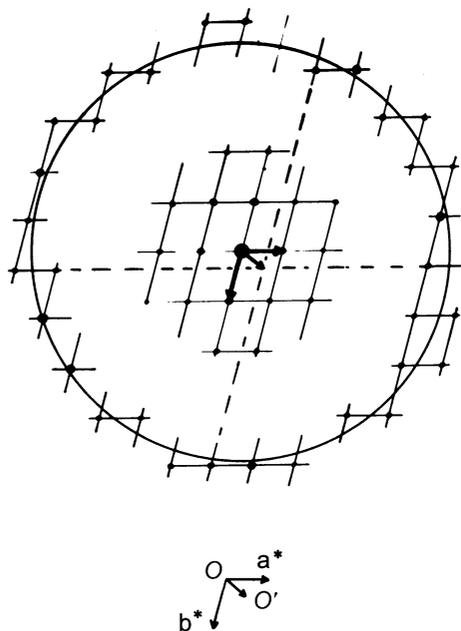


Fig. 5.4.1.2. A diffraction pattern with the crystal oriented at a zone axis. The lower diagram shows the zero-zone vectors \mathbf{a}^* and \mathbf{b}^* , and OO' , the projection on the xy plane of \mathbf{c}^* .

5.4.1.3. Non-zero-zone analysis

One pattern with well defined Laue zones taken at an arbitrary zone allows the recovery of a third vector not in the plane of the pattern. First find the components for the two shortest zero-zone vectors \mathbf{a}^* and \mathbf{b}^* (see Fig. 5.4.1.2). For the third vector, measure the x and y coordinates of a non-zero-zone vector. These are then transformed to components in the coordinate system defined by the two shortest vectors of the zero zone. Then the fractional part of each transformed component is taken. If the vector comes from a Laue zone of order n , these fractional parts must be divided by n . A transformation back to Cartesian coordinates gives the x and y components of the third vector \mathbf{c}^* , point O' in Fig. 5.4.1.2. In practice, it is best to measure a set of vectors at roughly equal angles around the zone so that an average can be taken to improve accuracy.

For certain space groups and special orientations, it is possible for half of the zero-zone reflections to be absent. If sufficient non-zero-zone vectors have been measured, two different vectors OO' should be found. New axes $(\mathbf{a}^* + \mathbf{b}^*)/2$ and $(\mathbf{a}^* - \mathbf{b}^*)/2$ must then be chosen and the x and y coordinates of \mathbf{c}^* recalculated.

The z component of \mathbf{c}^* is obtained (Fig. 5.4.1.1) from

$$c_z^* = L[1 - 1/(1 + r^2/L^2)^{1/2}]/n,$$

where r is the radius of the Laue circle of order n .

We now have the orientation matrix UB as

$$UB = \begin{pmatrix} a_x^* & b_x^* & c_x^* \\ a_y^* & b_y^* & c_y^* \\ 0 & 0 & c_z^* \end{pmatrix},$$

and the measurement of the pattern is complete.

After transformation of the axes defined by UB to the Bravais axes, the inverse of the resulting UB_{Bravais} will index the pattern using

$$\begin{pmatrix} h \\ k \\ l \end{pmatrix} = UB_{\text{Bravais}}^{-1} \begin{pmatrix} x \\ y \\ z \end{pmatrix}.$$

5.4.2. Kikuchi and HOLZ techniques (By A. Olsen)

Lattice-parameter determination based on selected-area electron-diffraction patterns requires accurate calibration of the camera constant K . This constant depends on the electron wavelength λ and the camera length L and is given by $K = \lambda L$. Because the camera constant cannot be determined with sufficient accuracy in a transmission electron microscope, a number of methods for determination of lattice parameters (or electron wavelength)

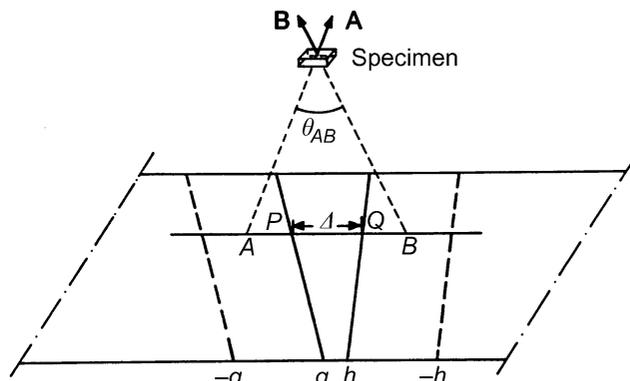


Fig. 5.4.2.1. Schematic diagram showing the geometry of a Kikuchi pattern.

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Substitution of (5.4.2.10) into (5.4.2.9) gives

$$2\mathbf{g}_3\mathbf{K} = -|\mathbf{g}_3|^2(1 + \Delta R_3/R_3). \quad (5.4.2.11)$$

From n measurements of intersections, the following equations are obtained:

$$h_{ji}u_j + k_{ji}v_j + l_{ji}w_j = -(1/2)(1/d_{ji})^2(1 + \delta_{i3}\Delta R_{j3}/R_{j3}),$$

$$i = 1, 2, 3, \quad j = 1, 2, \dots, n, \quad (5.4.2.12)$$

where h_{ji}, k_{ji}, l_{ji} are the indices (given in reciprocal space) of the Kikuchi lines, δ_{i3} is the Kronecker delta, u_j, v_j, w_j are the indices (given in real space) of the direction \mathbf{K}_j to the intersection number j , and d_{ji} is the interplanar spacing corresponding to the reflection h_{ji}, k_{ji}, l_{ji} and can be expressed in terms of the cell dimensions in real space. The length of the \mathbf{K}_j vectors can also be expressed in terms of the lattice parameters in real space a, b, c, α, β , and γ as

$$|\mathbf{K}_j| = (u_j^2a^2 + v_j^2b^2 + w_j^2c^2 + 2u_jv_jab\cos\alpha + 2u_jw_jac\cos\beta + 2v_jw_jbc\cos\gamma)^{1/2}. \quad (5.4.2.13)$$

Equations (5.4.2.12) can be solved with respect to u_j, v_j, w_j , and \mathbf{K}_j can then be expressed in terms of the lattice parameters by substituting the expressions for u_j, v_j, w_j from (5.4.2.12) into (5.4.2.13).

If the number of intersections is greater than the number of unknown lattice parameters, a least-squares-refinement procedure can be used. This involves minimizing the function

$$Q = \sum_j (|\mathbf{K}_j| - 1/\lambda)^2. \quad (5.4.2.14)$$

Because the expression for Q is non-linear in the lattice parameters, a refinement procedure can be used to solve the equations derived from (5.4.2.14) using the least-squares procedure. The accuracy in the lattice parameters or wavelength can be found by statistical methods. A computer program for refinement of the lattice parameters (or electron wavelength) is available (Olsen, 1976b). In this program, some of the lattice parameters can be held constant or kept equal during the refinement.

Methods based on measurements of distances between zone axes (poles) in the Kikuchi patterns (Thomas, 1970) are not very accurate because optical distortions make long-distance measurements inaccurate on the photographic plate or a magnified print.

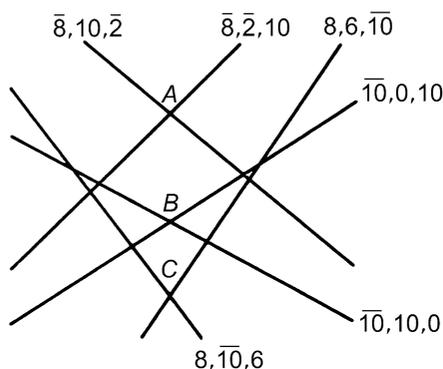


Fig. 5.4.2.3. Schematic diagram showing the indexing of the most prominent lines in the selected-area channelling pattern near the [111] zone of Si. Accelerating voltage: 25 kV.

The methods by Høier (1969) and Olsen (1976a) are based on 'near intersections'. Better accuracy may be obtained if the high voltage can be varied in order to obtain exact intersections. A simple method for determination of lattice parameters can be applied for crystals with symmetry as low as orthorhombic (Gjønnnes & Olsen, 1984). The method is a simplified version of the Uyeda *et al.* (1965) method. If two parallel Kikuchi lines belonging to different zones overlap, then:

$$2\mathbf{g}_i\mathbf{K} = -|\mathbf{g}_i|^2, \quad i = 1, 2;$$

$$(\mathbf{g}_1 \times \mathbf{g}_2)\mathbf{K} = 0, \quad |\mathbf{K}| = 1/\lambda. \quad (5.4.2.15)$$

These equations can be solved to give the ratio between lattice parameter and electron wavelength.

A simple, rapid procedure for accelerating-voltage (or electron-wavelength) determination of a transmission electron microscope has been described by FitzGerald & Johnson (1984). In their method, it is necessary to measure the ratio of two easily found distances between points defined by the intersections of Kikuchi lines near the {111} zone of a silicon crystal. It is not necessary to index the Kikuchi lines, because the method is based on (a) a particular crystal and (b) an easily recognizable crystal orientation, and because the points between which distances need to be measured are specified in their paper and can be easily found. Polynomials for converting the distance measurements both to electron wavelength and to accelerating voltage are given for the range from 100 to 200 kV. A 300 K temperature change must occur (temperature coefficient of 3×10^{-6} K) before the error in the lattice parameter of silicon due to thermal expansion becomes significant.

A method for measuring small local changes in the lattice parameter of bulk specimens based on selected-area channelling patterns has been described by Walker & Booker (1982). The method utilizes the small changes in the position of high-index channelling lines due to small changes in the lattice parameters, and is based on scanning electron microscopy (SEM). The method is rapid and convenient, is suitable for bulk specimens, and can be applied to areas only a few micrometres across. The method has been used for Si and GaP and is in this case based on the intersection of pairs of $\bar{8},10,2$, $\bar{10},10,0$, $8,\bar{10},6$ type lines (the points A, B, and C in Fig. 5.4.2.3). Selected-area channelling patterns from Si and GaP obtained under precisely the same conditions have the same characteristic array of lines, but with slightly different distances AB and BC. The detection limit of this method is at present 3 parts in 10^4 .

When a small electron probe is used to illuminate a crystal, as in convergent-beam electron diffraction (CBED), very fine lines are often found in the diffraction discs (Steeds, 1979). These lines are called HOLZ lines. They are due to upper-layer diffraction effects and can be used in lattice-parameter determination (Rackham, Jones & Steeds, 1974; Jones, Rackham & Steeds, 1977). For highest accuracy, relatively thick crystals are required. The limitation to the accuracy is set either by the weakness of the lines or by energy losses in the specimen. Relative changes in the lattice parameters can be measured to an accuracy of 1 part in 10^4 , whereas the accuracy in the absolute determination of lattice parameters is typically of an order of magnitude worse. The lattice parameters can be measured from crystal regions as small as 20 nm in diameter with an accuracy better than 1 part in 10^3 . If more accurate results are desired, it is necessary to make measurements on lines that are not affected by interactions between HOLZ reflections.